

What is claimed is:

1. A method for manufacturing an organic EL device, comprising:
 coating a composition including an organic EL material above a plurality of electrodes to form an organic EL layer above each of the electrodes;
 defining an effectively optical area in which the plurality of electrodes are formed;
 and
 defining a coating area being broader than the effectively optical area, in which the composition including an organic EL material is to be coated.
2. A method according to claim 1, wherein the coating area includes the perimeter of the effectively optical area.
3. A method according to claim 1, wherein the coating area located along the perimeter of the effectively optical area is a dummy area in which the composition including an organic EL material is also coated to form an organic EL layer.
4. A method according to claim 3 further comprising:
 forming a layer made of the same material as that of the electrodes in the dummy area; and
 coating the composition including an organic EL material on the layer.
5. A method according to claim 1 further comprising:
 providing a group of effectively optical areas formed of a plurality of the effectively optical areas on a substrate; and
 defining dummy areas around the effectively optical areas, respectively, and another dummy area encompassing the group of effectively optical areas.

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6. A method according to claim 3, wherein a process of coating of the composition, including an organic EL material is started at the dummy area prior to coating on the effectively optical area and ends at the dummy area after coating on the effectively optical area.
7. A method according to claim 1, wherein individual areas to be coated in the entirety of the coating area are disposed at a constant pitch from each other.
8. A method according to claim 7, wherein any one of the electrodes is disposed relative to adjacent ones of the electrodes at a constant pitch.
9. A method for manufacturing an organic EL device which includes an effectively optical area having a plurality of electrodes and an organic EL layer formed above each of the electrodes, the method comprising:
forming the organic EL layer both on areas to be the effectively optical area and on other areas not to be the effectively optical area.
10. A method for manufacturing an organic EL device which includes an effectively optical area having a plurality of electrodes and an organic EL layer formed above each of the electrodes, the method comprising:
further forming the organic EL layer in areas not having the electrodes and which are supposed to be the optically active area.
11. An organic EL device manufactured using a method according to claim 1.
12. An organic EL device having a plurality of electrodes and an organic EL layer formed above each of the electrodes comprising:
an effectively optical area in which the electrodes are formed; and

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a dummy area disposed around the effectively optical area, in which the electrodes are also formed.

13. An organic EL device according to claim 12 further comprising a bank layer disposed between the electrodes, wherein the organic EL layer in the dummy area is disposed on a layer made of the same material as that of the bank layer.
14. An organic EL device according to claim 13, wherein the bank layer includes an organic bank layer and an inorganic bank layer, and the organic EL layer in the dummy area is disposed on a layer made of the same material as that of the inorganic bank layer.
15. An organic EL device according to claim 14, wherein the bank layer is disposed laterally between portions of the organic EL layer in the dummy area.
16. An organic EL device according to claim 13, wherein the organic EL layer in the dummy area is disposed on a layer made of the same material as that of the organic bank layer.
17. An organic EL device according to claim 12, wherein the organic EL layer in the dummy area is disposed on a layer made of the same material as that of the electrodes.
18. An organic EL device according to claim 17, wherein the bank layer is formed laterally between portions of the organic EL layer in the dummy area.
19. An organic EL device according to claim 12, wherein adjacent portions of the organic EL layer are disposed at a constant pitch in both the effectively optical area and the dummy area.

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20. An organic EL device according to claim 12, wherein both the effectively optical area and the dummy area are provided on a substrate, and portions in the effectively optical area on the substrate have substantially the same cross-sectional structure as that of portions in the dummy area on the substrate.

21. An organic EL device including an effectively optical area having a plurality of electrodes and an organic EL layer formed on each of the electrodes, wherein the organic EL layer is formed both on areas supposed to be the effectively optical area and on other areas not supposed to be the effectively optical area.

22. An organic EL device including an effectively optical area having a plurality of electrodes and an organic EL layer formed above each of the electrodes, wherein the organic EL layer is also formed in areas not having the electrodes and which are supposed to be the effectively optical area.

23. An electronic device comprising an organic EL device according to any one of claims 12, 21, and 22.

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